

Effects of sputtering environment on the optical, electrical and optoelectronic properties of ZnSnN₂

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ZnSnN₂ is a member of ternary Zn-IV-N₂ semiconductors, where IV = Si, Ge or Sn. According to theoretical calculations and experimental results, Zn-IV-N₂ semiconductor materials have potential to replace III-nitride semiconductors. The wurtzite structure of II-IV-N₂ compounds is similar to the one of III-N semiconductors. It is then reasonable to expect similar electronic and optical properties as for InGaN, for example, direct bandgaps and large optical absorption coefficients[1][2]. Based on first-principles calculations, ZnSnN₂ becomes a promising material for photovoltaic. The most stable wurtzite-derived structure of bulk ZnSnN₂ was given to be the orthorhombic Pna2₁ phase by calculating the total energy per unit cell, band structure and electronic density of states[3]. Beside that, n-type carrier concentration was demonstrated in the first experimental investigations, which is up to 10²¹cm⁻³ and the optical band gap is approximate 2.1eV[4]. Up to now, there are very few reports related to the preparation of the ZnSnN₂ thin film and the most common are based on sputtering deposition.

In this research, ZnSnN₂ thin films are produced on glass substrate by co-sputtering technique at room temperature. By varying the composition (argon, nitrogen and hydrogen) of the deposition atmosphere, the optical and electrical properties of material were first evaluated. The optical band gap was determined by UV-VIS spectroscopy and ranges from 1.8eV to 2.08 eV. The n-type carrier concentration was recorded between 2.4e¹⁷ to 1.4e²⁰ cm⁻³, and the highest carried mobility as 1.68 cm²/V.s. These obtained results, compared to theory, confirm the potential use of ZnSnN₂ material as a photovoltaic absorber for a top cell of tandem solar cell[5]. In addition, the morphology and crystal structure were investigated by using SEM, AFM and X-ray diffraction. Nevertheless, right now, no real demonstration of carrier photogeneration has been reported. So, optoelectronic properties of the material are now investigated for applying ZnSnN₂ as an absorber layer.

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